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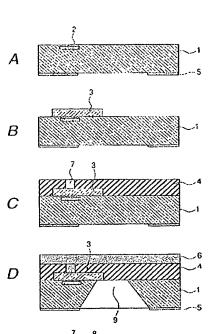
- (71) Applicant (for all designated States except US): CANON KABUSHIKI KAISHA [JP/JP]: 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP).
- (72) Inventors; and
- (75) Inventors/Applicants (for US only): KUBOTA, Masahiko [JP/JP]; c/o CANON KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). SUZUKI, Takumi [JP/JP]; c/o CANON KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). SATO, Tamaki [JP/JP]; c/o CANON

KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP), KANRI, Ryoji [JP/JP]; c/o CANON KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). HATTA, Maki [JP/JP]; c/o CANON KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). ASAI, Kazubiro [JP/JP]; c/o CANON KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). SHIBA, Shoji [JP/JP]; c/o CANON KABUSHIKI KAISHA. 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). HINO, Etsuko [JP/JP]; c/o CANON KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). ISHIKURA, Hiroe [JP/JP]; c/o CANON KABUSHIKI KAISHA, 3-30-2. Shimomaruko, Ohta-ku, Tokyo 1468501 (JP). OKANO, Akihiko [JP/JP]; e/o CANON KABUSHIKI KAISHA, 3-30-2, Shimomaruko, Ohta-ku, Tokyo 1468501 (JP).

- (74) Agents: OKABE, Masao et al.: No. 602, Fuji Bldg., 2-3, Marunouchi 3-chome, Chiyoda-ku, Tokyo 1000005 (JP).
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(54) Title: LIQUID DISCHARGE HEAD MANUFACTURING METHOD, AND LIQUID DISCHARGE HEAD OBTAINED USING THIS METHOD



(57) Abstract: According to the present invention, a method for manufacturing a liquid discharge head includes the steps of depositing a solid layer (3) for forming a flow path on a substrate (1) on which an energy generating element (2) is arranged to generate energy that is used to discharge liquid, forming, on the substrate where the solid layer is mounted, a coating layer (4) for coating the solid layer, forming a discharge port (7) used to discharge a liquid, through a photolithographic process, in the coating layer formed on the solid layer, and removing the solid layer to form a flow path (8) that communicates with the energy element and the discharge port, whereby a material used for the coating layer contains a cationically polymerizable chemical compound, cationic photopolymerization initiator and a inhibitor of cationic photopolymerization, and whereby a material of the solid layer that forms a boundary with a portion where the discharge port of the coating layer is formed contains a copolymer of methacrylic anhydride and methacrylate ester.

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